

Fig.1a
<Prior Art>

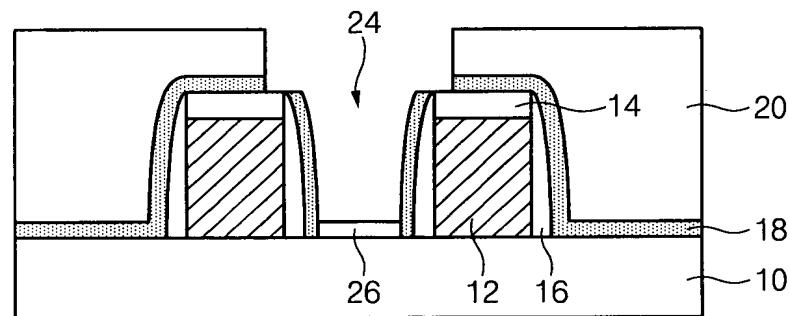


Fig.1b
<Prior Art>

Ho Seok LEE et al.
"Method for Forming Contact Hole of Semiconductor
Device"
Attorney Docket No.: 40296-0019

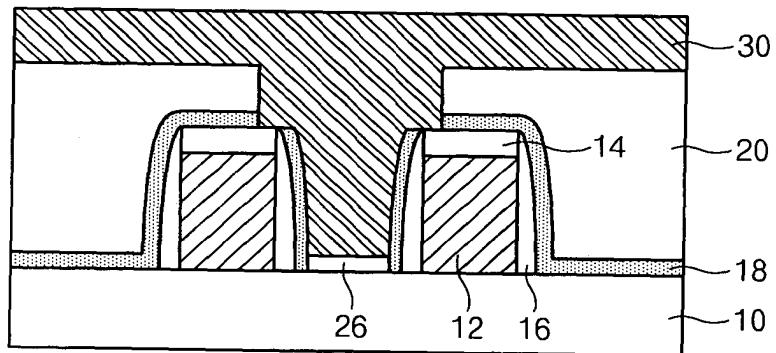


Fig.1c
<Prior Art>

Ho Seok LEE et al.
"Method for Forming Contact Hole of Semiconductor
Device"
Attorney Docket No.: 40296-0019

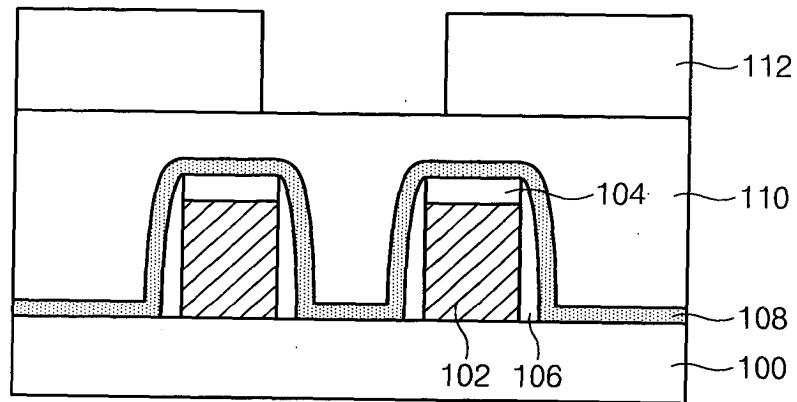


Fig.2a

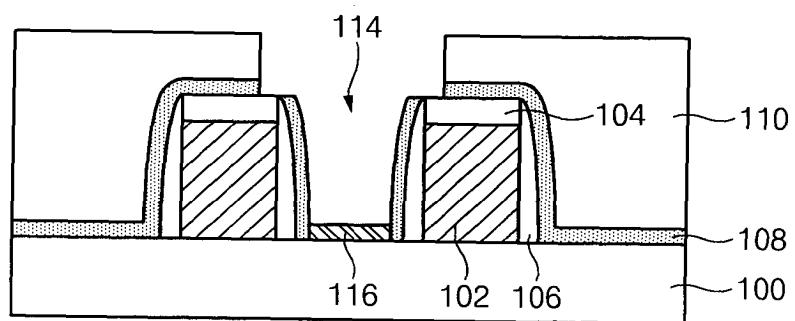


Fig.2b

Ho Seok LEE et al.
"Method for Forming Contact Hole of Semiconductor
Device"
Attorney Docket No.: 40296-0019

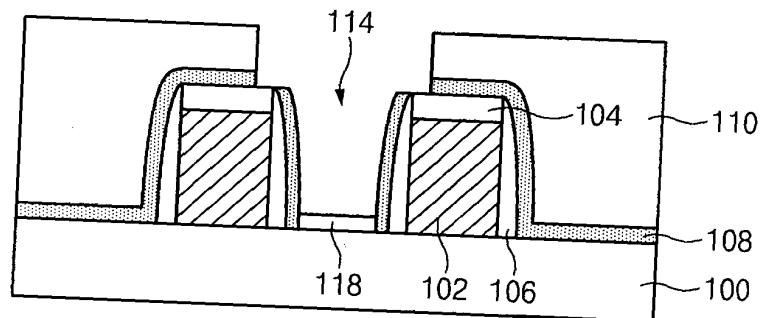


Fig. 2c

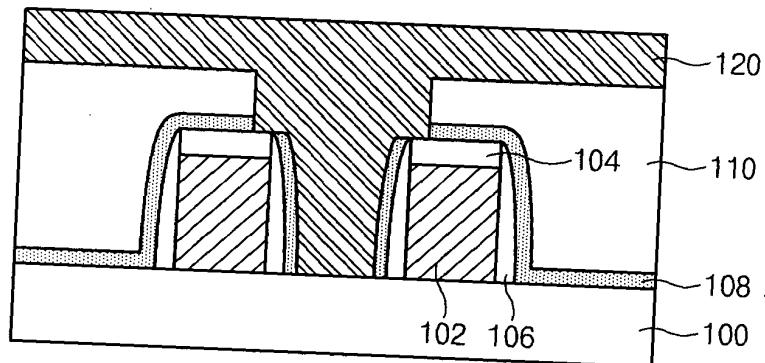


Fig. 2d

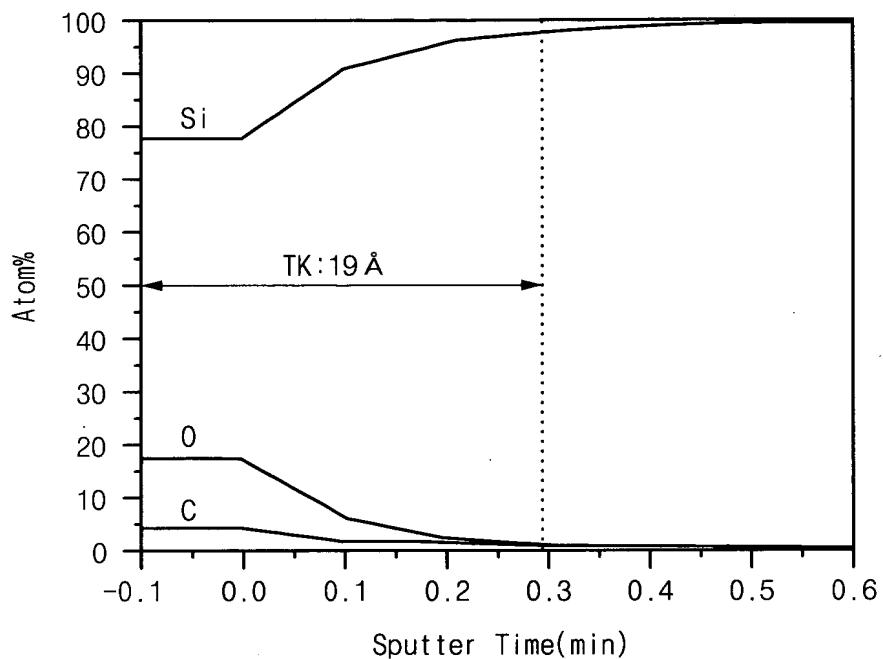


Fig.3a

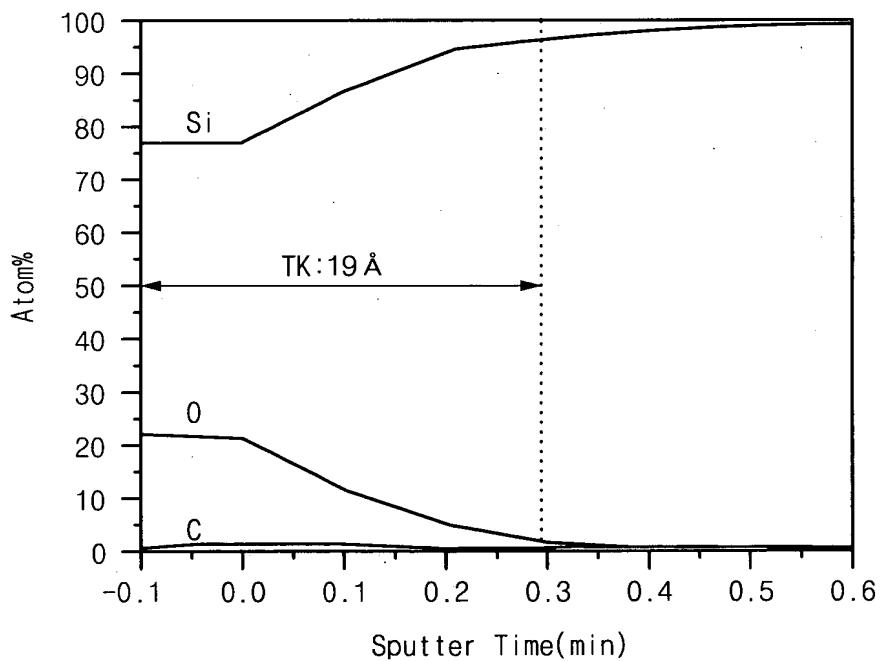


Fig.3b

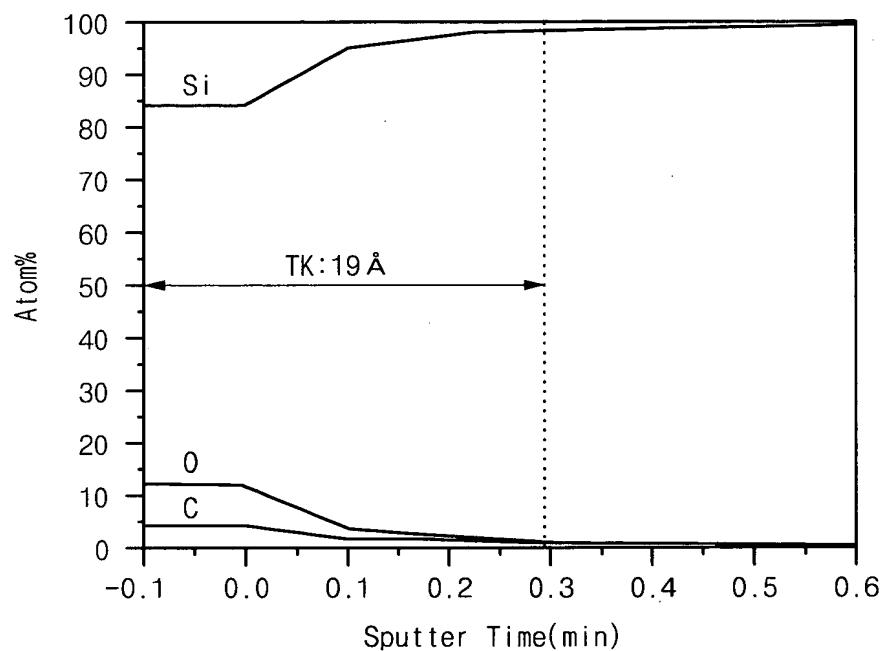


Fig.3c

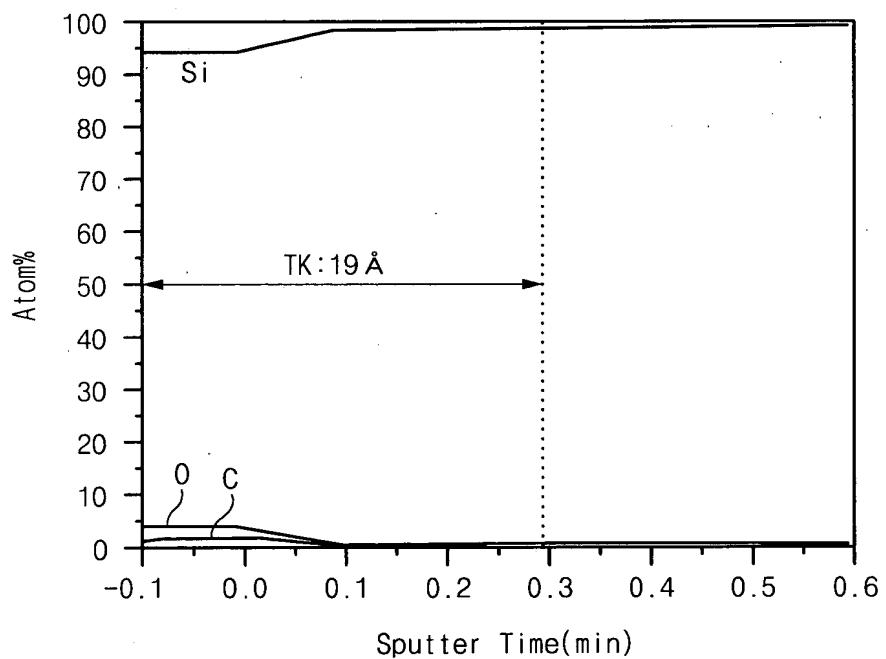


Fig.3d